

Porosity-dependent photoelectrochemical activity of double-layered TiO₂ thin films deposited by spin-coating method

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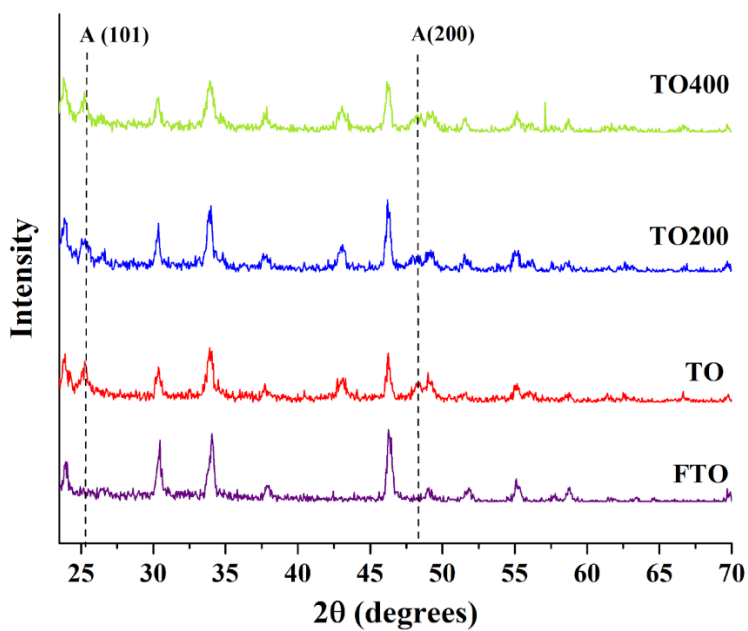


Figure S1. XRD patterns of prepared films and FTO for comparison

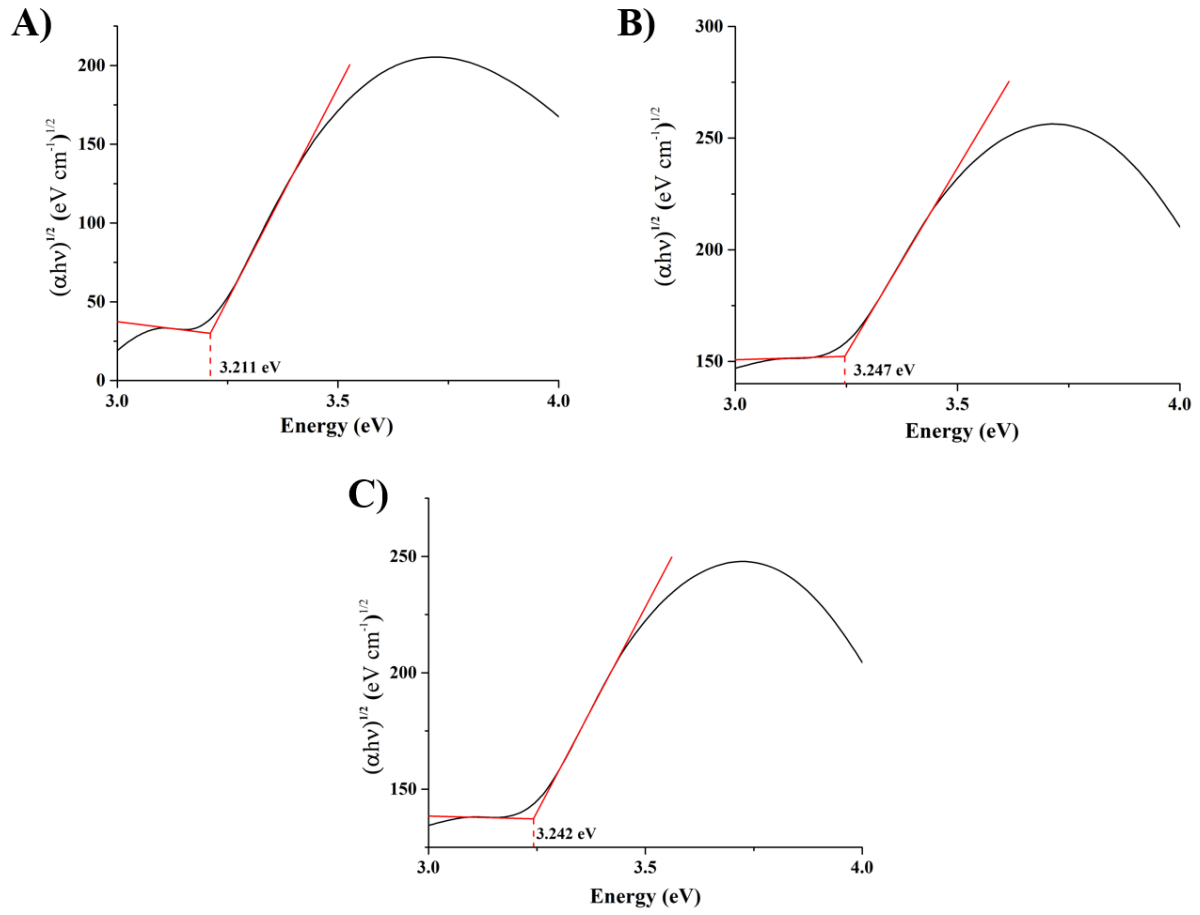


Figure S2. Tauc plots and calculated bandgaps of TO (A), TO200 (B), and TO400 (C) films.